

Raman Spectroscopy of 2D MoS₂ Interacting with Metals

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Abstract: The research on molybdenum disulphide (MoS₂) has progressed remarkably in the last decade, prompted by the increasing interest for this material as a potential candidate in future ultrathin optoelectronic devices. MoS₂ is a layered semiconductor with a gap in the visible region, which can be exfoliated down to the mono-layer form. Since the discovery of the exceptional optoelectronic properties of 2D MoS₂, Raman spectroscopy has been extensively used as a tool to characterize the structure and thickness of MoS₂ films. Recent works on MoS₂-metal interfaces have shown that Raman spectra are significantly affected by the interaction with metals. However, a complete understanding of how such interaction modifies the MoS₂ vibrational properties is still lacking. Studying this subject with both experimental and theoretical methods will provide fundamental insight into the interface physics of MoS₂-metal systems, which is crucial for the fabrication of metal contacts and for the development of metal-assisted synthesis methods. This review summarizes the main results concerning Raman spectroscopy studies of heterosystems between MoS₂ and transition metals, providing both a basis and directions for future research.

Keywords: MoS₂; Raman spectroscopy; 2D materials; transition metal dichalcogenides; metal contacts; vibrational modes



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1. Introduction

Transition metal dichalcogenides (TMDs) are a technologically relevant class of layered materials that have attracted increasing interest due to their intriguing optical and electronic properties [1–10]. The most prominent member of the TMD class is molybdenum disulphide (MoS₂), which has a longstanding tradition of industrial applications as a solid lubricant and catalyst for desulfurization reactions. Following the isolation of graphene and the discovery of its exceptional properties, the interest in layered materials such as MoS₂ and other TMDs shifted on the study of 2D systems formed by one or few-layers, obtained by exfoliation of a bulk crystal. This study led to the remarkable discovery of the gap variation and indirect-to-direct gap transition occurring in MoS₂ and other TMDs as the number of layers is reduced down to a single one [11]. The observation of this bandstructure evolution boosted the research on MoS₂ as a promising candidate for 2D optoelectronic devices, prompted also by its high carrier mobility at room temperature [12].

The future application of MoS₂ in real devices requires one to face several challenges, such as synthesizing large-area films of high crystalline quality, assessing their stability under operating conditions, and obtaining a detailed understanding of the interface properties of MoS₂-metal heterosystems. The latter is necessary to design and engineer functional metal contacts in electronic devices. Moreover, the deposition of MoS₂ on metal surfaces—either by exfoliation or bottom-up growth—has been recently explored as a promising method to obtain mono-layer MoS₂ films of a relatively large-area [13–18]. The interaction with metals is known to have profound effects on the electronic properties of mono-layer MoS₂ [19,20],

due to the hybridization with metal states causing, e.g., band gap renormalization and partial metallization [20,21]. Less is known about the impact of a metal interface on the vibrational properties of 2D MoS₂, and about how they are affected by metal-induced effects, such as interface strain and charge transfer.

Raman spectroscopy has been proved to be one of the most valuable techniques to characterize the lattice vibrations of 2D MoS₂ and obtain information on its structure as well as the influence of additional factors, such as strain, doping, and defects [22–34]. Notably, Raman spectroscopy is highly sensitive to the number of atomic layers [23,24], providing a widely used method to measure the thickness of MoS₂ films. This is the main reason why Raman spectroscopy is extensively used to characterize exfoliated or chemical-vapor-deposited (CVD) MoS₂, which is typically supported by SiO₂/Si substrates. Since MoS₂ interacts weakly with such substrates, it can be considered as quasi-freestanding, and its properties are unperturbed by the support. However, when MoS₂ interacts with metals, Raman spectra show significant deviations from the vibrational features of quasi-freestanding MoS₂ [16,35–43], suggesting a strong sensitivity of MoS₂ Raman active modes to metal-induced interface effects, such as strain and charge transfer. Similarly to other MoS₂ heterostructures [44], Raman spectra of MoS₂-metal systems can therefore be used as a fingerprint of the interaction strength and other interface effects, providing a valuable insight into the interface physics of these systems.

In the last decade, MoS₂ and its heterostructures have been studied using a wide range of fabrication approaches and characterization techniques. Consequently, the related literature has grown enormously, and many reviews focusing on different aspects of this research field have been published in recent years [1–10]. We refer the reader to such works for a more comprehensive overview of the fabrication and characterization techniques that have been applied to the study of MoS₂ and its heterostructures. The scope of this review is to focus on recent Raman spectroscopy studies of MoS₂-metal heterosystems. The interest in these systems embraces many potential applications and categories of metals, including, e.g., MXenes [45,46] or conductive polymers [47]. In particular, we will focus on the Raman spectroscopy studies of MoS₂ heterostructures with transition metals, which are interesting systems for electronic devices and metal-assisted MoS₂ synthesis. The discussion of these studies is presented in Section 3. Before that, Section 2 provides a short summary of the vibrational properties of quasi-freestanding MoS₂, which are useful to the discussion of MoS₂-metal systems.

2. Lattice Vibrations of Quasi-Freestanding MoS₂

Bulk MoS₂ is a layered semiconducting material composed by weakly bound layers that can be easily exfoliated, e.g., using common adhesive tape. The mono-layer is composed of a plane of Mo atoms covalently bound to two planes of S atoms. The most stable bulk phase is the 2H polytype, whose structure is shown in Figure 1a. Its unit cell consists of two Mo and four S atoms, and the crystal has D_{6h} symmetry. The mono-layer has D_{3h} symmetry, and its unit cell contains only one Mo and two S atoms. According to the irreducible representation of D_{3h} , the optical Raman active modes of the mono-layer correspond to E' , E'' , and A_1' symmetries [48]. The geometries of these modes, respectively, correspond to the Raman active E_{2g}^1 , E_{1g} , and A_{1g} modes in the bulk. Albeit the notation of vibrational modes varies among mono-layer, bi-layer, and bulk (precisely, the symmetry changes from D_{3h} in odd-layers MoS₂ to D_{3d} in even-layers MoS₂), the use of the bulk notation to also label the vibrational modes of few-layers MoS₂ is quite common in the literature. In this review, we use the same notation used in the papers that we will discuss, partly to avoid conflicts with the original figure labeling.

Figure 1b reports the vibration geometries of the E_{1g} , E_{2g}^1 , and A_{1g} modes. E_{1g} and E_{2g}^1 correspond to in-plane vibrations and are doubly degenerate at the zone center, whereas A_{1g} is an out-of-plane vibration of S atoms. In both bulk and mono-layer MoS₂, the E_{1g} (E'') mode (at ~ 280 cm⁻¹) requires a scattering geometry involving an out-of-plane component of the field [22,26]. Therefore, it is usually not detected in backscattering configuration,

where the laser polarization is parallel to the MoS₂ basal plane. Typical Raman spectra of mono-layer MoS₂ show the E' mode at ~ 384 cm⁻¹ and the A'_1 mode at ~ 403 cm⁻¹. The frequency of the two modes notably depends on the number of MoS₂ layers (Figure 1c). As the number of layers increases, E'_{2g} gradually downshifts while A_{1g} upshifts (Figure 1d,e). For a number of layers larger than six, the frequencies of both modes converge to the bulk values, namely, 382 cm⁻¹ for E'_{2g} and 408 cm⁻¹ for A_{1g} . Due to this opposite shift, the frequency difference between the two modes in the mono-layer is 19 cm⁻¹, and it gradually increases to 26 cm⁻¹ in the bulk. Therefore, this parameter can be used to infer the thickness of an MoS₂ film [23–25].

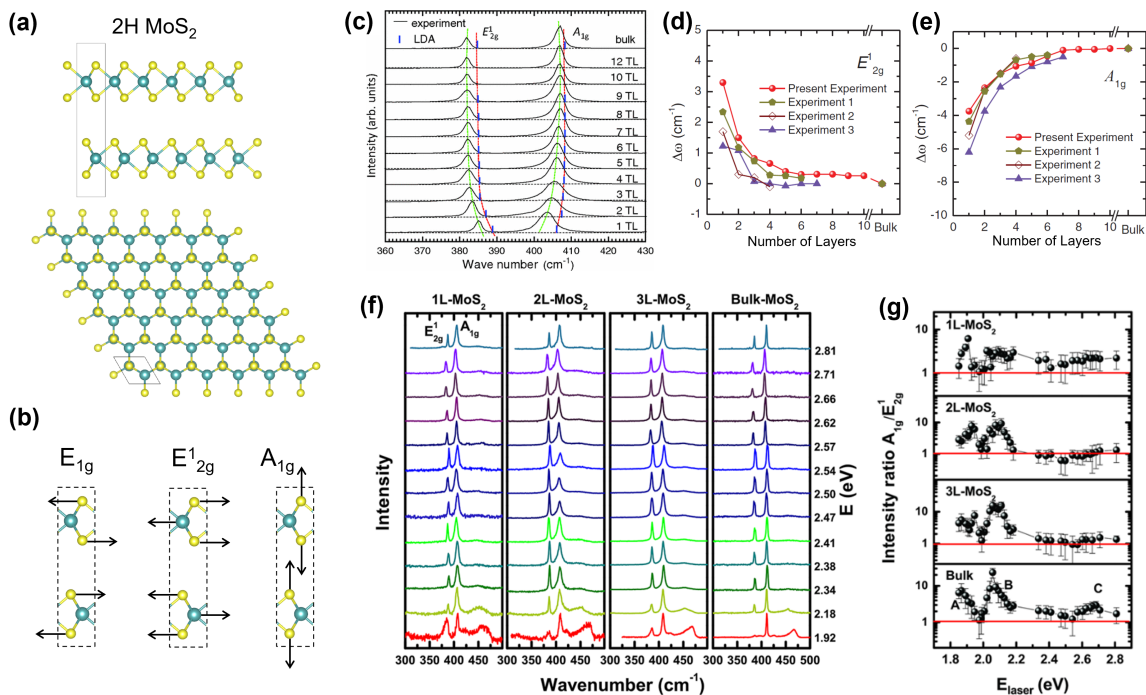


Figure 1. (a) Crystalline structure of 2H-MoS₂. Top: Side view of a bi-layer structure. Bottom: top view. The black solid line marks the bulk unit cell. (b) Optical Raman active vibrational modes of bulk MoS₂. E_{1g} and E'_{2g} correspond to in-plane vibrations and are doubly degenerate at Γ . A_{1g} corresponds to out-of-plane vibrations of S atoms. (c) Evolution of Raman spectra for increasing number of MoS₂ layers (TL stands for tri-layer, i.e., an S-Mo-S layer). The peak positions of E'_{2g} and A_{1g} (green lines) are compared to theoretical calculations (red lines). Excitation wavelength: 532 nm. (d) Frequency shifts of A_{1g} and (e) E'_{2g} , as a function of the number of layers. (c–e) reproduced with permission from ref. [24]. (f) Raman spectra and (g) A_{1g}/E'_{2g} intensity ratio of mono-, bi-, tri-layer, and bulk MoS₂ at different excitation energies. (f,g) reproduced with permission from ref. [49].

The intensity of Raman modes depends on the excitation wavelength, and resonance scattering can also enhance second-order processes. The latter effect is particularly evident when the excitation energy is close to the energy of the A exciton (1.88 eV at room temperature). The result is the resonant Raman spectrum of MoS₂, which has been extensively analyzed in previous works [50–52]. Carvalho et al. [49] have measured the Raman spectra of mono-, bi-, tri-layer, and bulk MoS₂ using more than 30 different laser excitation lines covering the visible range (1.85–2.81 eV) (Figure 1f). They analyzed the intensity of E'_{2g} and A_{1g} modes as a function of the excitation energy and found out that the excitonic A , B , and C transitions enhance the intensity of both modes. The intensity ratio A_{1g}/E'_{2g} plotted in Figure 1g also shows that A_{1g} is typically more intense than E'_{2g} , being the ratio larger than 1 for almost all excitation energies in the investigated spectral range.

The behavior of MoS₂ vibrational modes is also affected by other perturbations, such as strain, doping, and defects. We will briefly review the effects of these three main factors as they can also be relevant in the following discussion of metal-MoS₂ heterosystems.

Strain has important consequences on the electronic bandstructure, phonon dispersion, and charge transport properties. Several works have shown the possibility of sensibly tuning the MoS₂ band gap by applying moderate uniaxial or biaxial in-plane strain [27–31]. The effect of in-plane strain on the vibrational properties depends on whether the strain is uniaxial or biaxial. Uniaxial strain breaks the symmetry of the crystal lattice in the basal plane and lifts the degeneracy of E' at Γ . This effect can be observed in Raman spectra as a splitting of the E' mode for increasing strain. Conley et al. [27] measured such splitting as a function of tensile strain between 0 and 2% (Figure 2a,b) and found that while E' is strongly sensitive to in-plane uniaxial strain, A'_1 is essentially unperturbed. Biaxial strain, on the other hand, does not produce anisotropy in the crystal lattice. Therefore, the degeneracy of E' is not lifted. Both modes upshift (downshift) as compressive (tensile) biaxial strain is applied. Lloyd et al. [29] studied the effect of tensile biaxial strain by applying a pressure difference to MoS₂ layers suspended over cylindrical microcavities (Figure 2c). They reported a softening of both modes that is more pronounced in mono-layer MoS₂ (Figure 2d). The Raman modes downshift linearly at a rate of 1.7 cm⁻¹/‰ for A_{1g} and 5.2 cm⁻¹/‰ for E_{2g}^1 . Interestingly, they also observed that as biaxial strain increases, the A_{1g}/E_{2g}^1 intensity ratio significantly decreases below 1, as also supported by theoretical calculations [32].

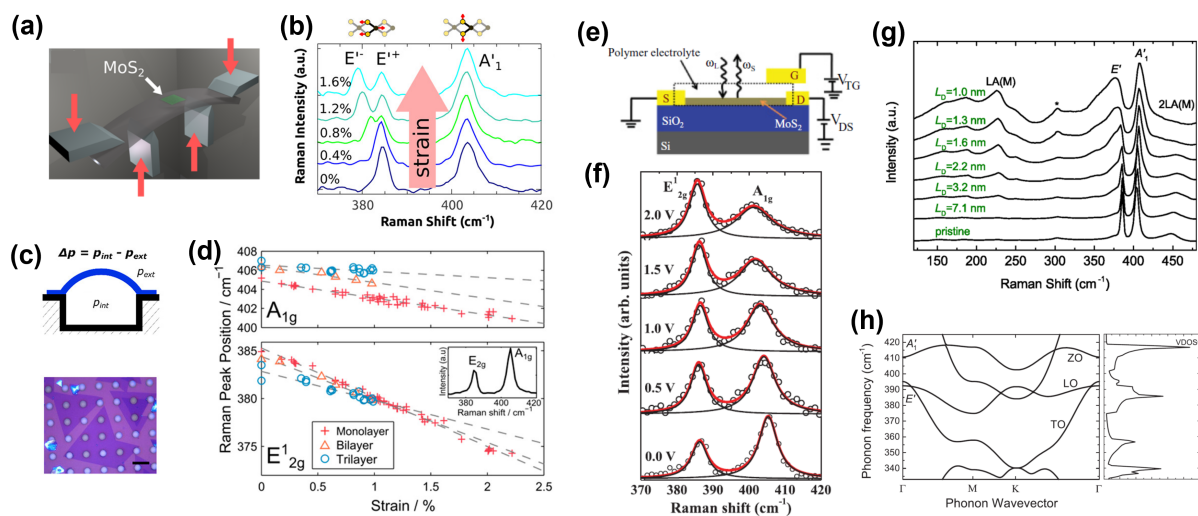


Figure 2. (a) Schematics of the setup used to apply uniaxial tensile strain to MoS₂ in ref. [27]. (b) Raman spectra of mono-layer MoS₂ for increasing uniaxial tensile strain (excitation wavelength: 532 nm). (a,b) reproduced with permission from ref. [27]. (c) Top: schematics of the setup used to apply biaxial tensile strain to MoS₂ in ref. [29]. Bottom: optical micrograph of mono-layer MoS₂ crystals over an array of cylindrical microcavities. (d) Raman frequencies of A_{1g} (top) and E_{2g}^1 (bottom) as a function of biaxial tensile strain (excitation wavelength: 532 nm). (c,d) reproduced with permission from ref. [29]. (e) Schematics of the top-gated transistor used to modulate the electron concentration of mono-layer MoS₂ in ref. [33]. (f) Raman spectra of mono-layer MoS₂ for increasing electron doping level (excitation wavelength: 514.5 nm). Circles: experimental data; black lines: fits of Raman modes; red line: total fit. (e,f) reproduced with permission from ref. [33]. (g) Evolution of Raman spectra of mono-layer MoS₂ as a function of defect density (excitation wavelength: 532 nm). The asterisk refers to a Raman peak of the Si substrate. (h) Calculated phonon dispersion of E' and A'_1 [34]. (g,h) reproduced with permission from ref. [34].

Doping generally has a strong impact on the vibrational properties of a crystal as changes in the electron concentration modify the electron-phonon coupling. Chakraborty et al. [33] studied the correlation between doping and the behavior of Raman modes in mono-layer MoS₂. They used a top-gated mono-layer MoS₂ transistor to modulate the electron concentration up to $2 \times 10^{13} \text{ cm}^{-2}$ (Figure 2e). Raman spectra taken at different gate voltages show that A'_1 strongly depends on the doping level, whereas E' is much less sensitive. For the maximum electron concentration, the A'_1 frequency softens by 4 cm^{-1} and the linewidth broadens by 6 cm^{-1} . The E' mode downshifts by only 0.6 cm^{-1} , and its linewidth is not appreciably affected. This result is explained in terms of a stronger electron-phonon coupling of the A'_1 mode compared to E' , confirmed with first-principles DFT calculations and symmetry arguments.

Variations in the frequency and shape of Raman peaks can be also due to lattice defects. In general, due to translation symmetry, a crystalline material satisfies the Raman fundamental selection rule $\mathbf{q} \approx 0$ (\mathbf{q} is the phonon wavevector), leaving only the zone center phonons as Raman active. In contrast, due to the loss of long-range order, the \mathbf{q} -selection rule is relaxed in a defective lattice, thus allowing other features related to the phonon dispersion away from the zone center to be detected in Raman spectra. Mignuzzi et al. [34] studied the Raman response of defective mono-layer MoS₂ flakes, exfoliated from the bulk on SiO₂ and then bombarded with different densities of Mn⁺ ions. The degree of disorder is quantified by the average interdefect distance L_D , which can be derived from the ion density. Figure 2g reports the Raman spectra obtained for different values of the L_D parameter. As disorder increases (i.e., decreasing L_D), E' and A'_1 change in both their widths and frequencies. The increasing defect density produces a downward shift of the E' mode and an upward shift of A'_1 . This opposite trend is due to the phonon dispersion of the corresponding branches (Figure 2h): moving away from Γ , the frequency of the ZO branch increases, while that of the LO and TO branches decreases. The asymmetric broadening of the two main Raman modes can be ascribed to the activation of the ZO, TO, and LO phonons at the M point of the Brillouin zone.

3. Vibrational Properties of Metal-MoS₂ Heterosystems

The interface properties of MoS₂-metal junctions are of key importance for the performances of MoS₂-based devices [53–55]. The charge transport at the MoS₂-metal interface is strongly dependent on the interaction between the two materials and metal-induced modifications to MoS₂ electronic structure, e.g., due to Fermi level pinning and hybridization with metal states [19–21,56]. Strain and charge transfer induced by the contact with metals are additional interface phenomena that can perturb the MoS₂ properties. As discussed in the previous section, Raman spectroscopy is sensitive to strain and doping effects and can therefore provide valuable insight into the interface properties of metal-MoS₂ heterosystems.

Different fabrication approaches have been used for the experimental investigation of such systems. We can divide them in three categories:

- The deposition of a metal film on the MoS₂ surface.
- The exfoliation of a bulk MoS₂ crystal on metals.
- The direct growth of MoS₂ layers on a metal surface.

These approaches produce metal-MoS₂ systems with different interface morphologies, therefore giving different results concerning the study of the vibrational properties. We will review the three fabrication approaches and the corresponding Raman studies in the following subsections.

3.1. Metal Deposition on MoS₂

In the first approach, the heterostructure is fabricated by depositing a metal film onto the MoS₂ surface. This approach is what is normally used to make metal contacts for electronic devices. The deposition is typically performed by evaporation under vacuum onto exfoliated or CVD-grown MoS₂ flakes supported by SiO₂.

Gong et al. [35] studied the effect on mono-layer MoS₂ of the contact with three different metals, namely, Pd, Au, and Ag. All three metallic films have the same average thickness, i.e., 2 nm, but their morphology is different: Pd forms a smooth film that wets MoS₂ uniformly, whereas Au and Ag form rougher films, showing a tendency to agglomerate in nanoclusters (Figure 3a). The Raman spectra of the Pd- and Au-covered mono-layer MoS₂ (Figure 3b) show an upward shift of the A_{1g} mode and a downshift of E_{2g}¹. The former is attributed to the increased stiffness of the vertical vibration of S atoms due to the interaction with the metal. The latter is associated with the combined effect of two different contributions: the enhanced electron screening provided by the metal, which weakens the planar interionic interaction, and the in-plane metal-induced strain that occurs where MoS₂ is in close contact with the metallic film or clusters. The strain effect depends on the homogeneity of the contact between metal and MoS₂ and thus on the film morphology at the metal-MoS₂ interface. The nonuniform morphology of the Au and Ag films produces regions of different contact with MoS₂. The E_{2g}¹ splitting observed for Au and Ag (Figure 3b,c, see the vertical dashed lines and the two fitting components of the 2 nm-Au curve) is explained as being due to two different contact regions of the metal-MoS₂ nonuniform interface. While the whole MoS₂ flake is screened by the metal film, resulting in the softening of E', the parts of MoS₂ under closer contact with the metal are strained, producing further softening of the same mode, which results in an additional peak at lower frequency.

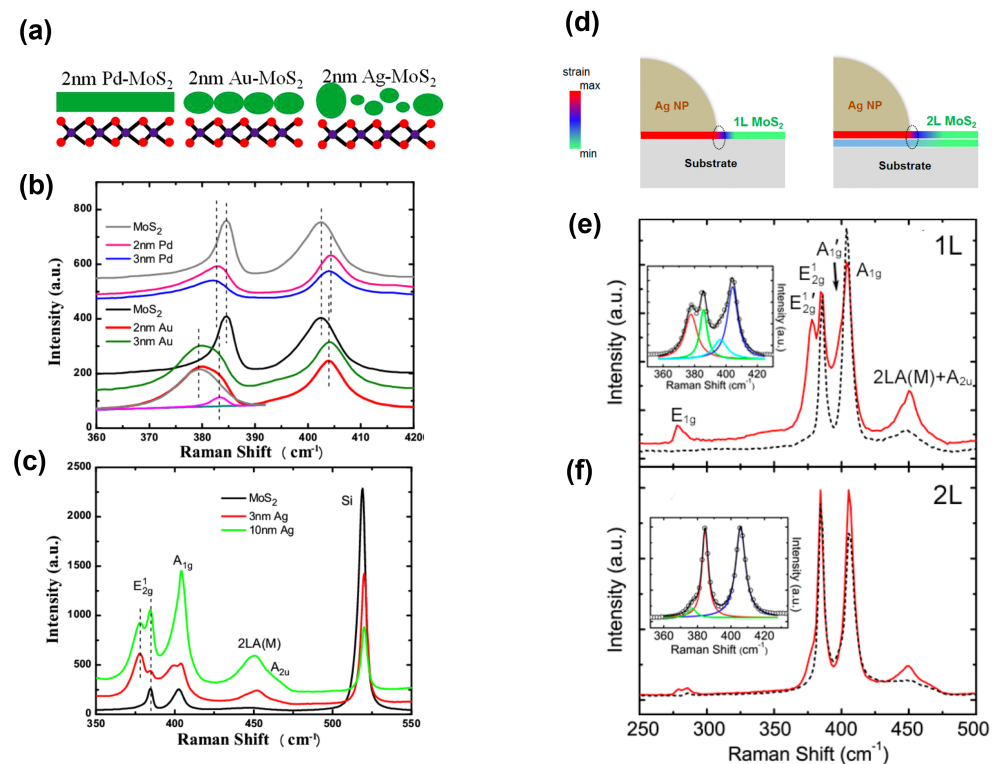


Figure 3. (a) Schematics of Pd, Au, and Ag film morphology on MoS₂. (b) Raman spectra of MoS₂ covered by different thicknesses of Pd and Au, compared to pristine MoS₂ (grey and black lines). (c) Raman spectra of MoS₂ covered by different thicknesses of Ag, compared to pristine MoS₂ (black line) (excitation wavelength: 532 nm). (a–c) reproduced with permission from ref. [35]. (d) Schematics of the boundary between an Ag nanoparticle and mono- (left) and bi-layer (right) MoS₂. The color gradient indicates local strain. The dotted circle marks the hot spot where the electric field is plasmonically enhanced. (e,f) Raman spectra of (e) mono-layer and (f) bi-layer MoS₂ covered by Ag nanoparticles (red lines), compared to pristine MoS₂ (black dashed lines) (excitation wavelength: 488 nm). Insets: fit of the primary Raman modes. (d–f) reproduced with permission from ref. [36].

Similar interpretations based on local strain at nonuniform interfaces are also adopted in other works to qualitatively explain the splitting of the E' mode in metal-covered mono-layer MoS₂ [36,55]. Sun et al. observed such a splitting in Raman spectra of 5 nm-sized Ag nanoparticles deposited on mono-layer MoS₂ (Figure 3d,e). In this case, E_{2g}^1 and A_{1g} peaks of Ag/MoS₂ remain at the same positions as pristine MoS₂ (Figure 3e). However, two new peaks downshift from E_{2g}^1 and A_{1g} modes (labeled as $E_{2g}^{\prime 1}$ and $A_{1g}^{\prime 1}$ in Figure 3e, see also inset). In mono-layer Ag/MoS₂ (Figure 3e), the downshifts of $E_{2g}^{\prime 1}$ and $A_{1g}^{\prime 1}$ are ~ 8 and ~ 7.9 cm⁻¹ from E_{2g}^1 and A_{1g} , respectively. They attributed the origin of these new peaks to the local strain of MoS₂ at the boundary of Ag nanoparticles. The strain-induced Raman peaks are enhanced by the strong electric field at the metal-MoS₂ boundary, produced by the Ag surface plasmon excitation. The relative intensity of these peaks becomes much weaker in thicker MoS₂ flakes (Figure 3f) because the Raman signals from the less-strained lower layers are also locally enhanced by the plasmon resonance, and they dominate the signal from the strained top layer (Figure 3d).

The study of junctions fabricated via metal deposition on MoS₂ is useful to understand the properties of contacts in MoS₂ devices since it relies on the same fabrication process. However, this method does not offer high control on the interface morphology, critically depending on metal wettability and deposition parameters. The resulting nonuniform metal-MoS₂ contact complicates the interpretation of Raman features and accounts for the poor consistency among the studies based on this approach.

3.2. MoS₂ Exfoliation on Metals

In the second approach, MoS₂ layers are deposited on a metal surface through mechanical exfoliation of a bulk crystal. Recent works have shown that this method can be used to produce large-area mono-layer MoS₂ films [13–16]. Velický et al. [15] demonstrated that the mechanical exfoliation of MoS₂ on gold produces mono-layer flakes up to a centimeter scale. The effectiveness of this technique critically depends on the cleanliness and smoothness of the Au surface. As shown in Figure 4a,b, the average area percentage of mono-layer MoS₂ is 70–80% on freshly cleaned Au but strongly decreases as the Au surface is exposed to air for a few minutes. Concurrently, the proportion of bulk flakes increases. The exfoliation of a single MoS₂ layer is facilitated by the stronger van der Waals (vdW) interaction with Au, compared to the interlayer vdW interaction in bulk MoS₂. However, the Au-MoS₂ interaction becomes weaker for increasing air exposure because the Au surface gets covered by airborne contaminants (Figure 4c). A similar trend is observed for increasing surface roughness, due to the decrease in the contact area between Au and the first MoS₂ layer, which reduces their mutual interaction.

In a follow-up paper by the same group [37], the vibrational properties of MoS₂ exfoliated on Au were studied by conventional and tip-enhanced Raman spectroscopy (TERS). The Raman spectra reported in Figure 4d show the comparison between MoS₂/Au and MoS₂/SiO₂ for different MoS₂ thicknesses. In mono-layer MoS₂/Au (red solid line), the in-plane E' mode downshifts and broadens compared to MoS₂/SiO₂ (red dotted line), while the A_1' mode shows two components: a low-frequency peak ($A_1'(L)$) at 396.4 ± 0.3 cm⁻¹, and a high-frequency one ($A_1'(H)$) at 403.7 ± 0.2 cm⁻¹, i.e., approximately the same frequency of A_1' in MoS₂/SiO₂. These Raman features are interpreted in terms of a nonuniform contact between MoS₂ and Au, due to the roughness of the Au surface (see the schematic inset in Figure 4d). The heterogeneous contact leads to a biaxial tensile strain distribution between 0.6% and 1.9%, causing the downshift and broadening of E' (centered at 378.2 ± 0.6 cm⁻¹). The $A_1'(L)$ component is attributed to n-type doping of the MoS₂ regions, which strongly interact with the Au substrate, whereas the $A_1'(H)$ component is the contribution coming from the suspended and undoped MoS₂ regions (see inset at the bottom of Figure 4d). The interaction with Au only produces significant effects in the first MoS₂ layer. Bi-layer MoS₂ (blue line in Figure 4d) is only partially affected by the Au substrate, while for more than three layers the effects of strain and doping are irrelevant and the spectra are very similar to MoS₂/SiO₂.

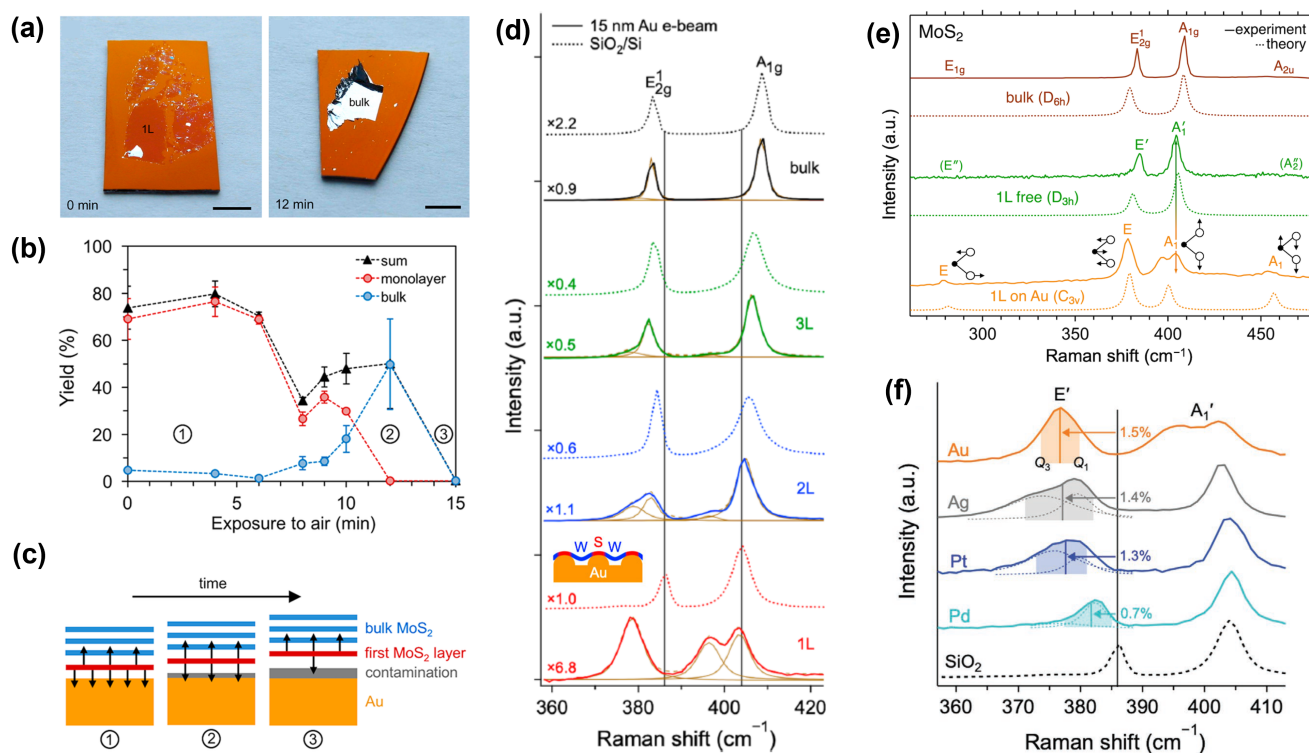


Figure 4. (a) Optical images of MoS₂ exfoliated on 7.5 nm Au immediately after (left) and after 12 min (right) the Au substrate is exposed to air. Scale bars: 5 mm. (b) Average exfoliation yield as a function of air exposure time for mono-layer (red circles), bulk (blue circles), and the sum of the two (black triangles). (c) Schematic depiction of the evolution of the adhesion forces between different surfaces with increasing exposure time. (a–c) reproduced from ref. [15] under CC-BY license. (d) Raman spectra of mono- (1L), bi- (2L), tri-layer (3L), and bulk MoS₂ on 15 nm e-beam Au (solid) and SiO₂/Si (dotted) (excitation wavelength: 532 nm). Inset: schematic depiction of MoS₂ on Au showing regions of strong (S) and weak (W) interaction modulated by the Au surface roughness. Adapted from ref. [37] under CC-BY license. (e) Experimental and calculated Raman spectra of mono-layer MoS₂ on Au (1L on Au), quasi-freestanding mono-layer MoS₂ (1L free), and bulk MoS₂ (bulk) (excitation wavelength: 532 nm). The insets schematically show the observed vibrational modes. Excitation wavelength: 488 nm. Reproduced from ref. [38] under CC-BY license. (f) Raman spectra of mono-layer MoS₂ on Au, Ag, Pt, and Pd, compared to that on SiO₂ (excitation wavelength: 532 nm). The vertical lines and shaded ranges represent strain medians and lower/upper quartiles (Q1/Q3), respectively. Reproduced from ref. [39] under CC-BY license.

The strong interaction with Au lowers the symmetry of mono-layer MoS₂ from D_{3h} to C_{3v} , due to the breaking of the reflection symmetry in the basal MoS₂ plane. This change of symmetry activates the geometry-forbidden E'' Raman mode at $\sim 280\text{ cm}^{-1}$ and the symmetry-forbidden A_2'' IR mode at $\sim 455\text{ cm}^{-1}$ (Figure 4e) [38]. As shown in Figure 4e, these modes are undetected in quasi-freestanding mono-layer MoS₂ and for thicker MoS₂ crystals (the visibility of these modes in bulk MoS₂ can be attributed to resonance effects).

The exfoliation of MoS₂ on other metals has been also investigated [39]. These experiments showed that gold is the best substrate in terms of the lateral size of the mono-layer flakes. A moderate exfoliation yield is achieved for other precious metals, including Pt, Pd, and Ag, while hardly any exfoliated material is found on base metals, such as Cu, Ni, Co, Cr, and Ti. This result depends on the ability of a metal to resist oxidation because the surface oxide layers reduces the MoS₂-metal binding strength. The exfoliation yield also correlates to the interfacial strain, which is inferred from the downshift of E' observed in the Raman spectra of Figure 4f. Despite its relatively high propensity to oxidation, Ag was

found to have a larger exfoliation yield than Pd and Pt. This result is attributed to the larger tensile strain of MoS₂ on Ag, which might facilitate a mechanical pinning of the first MoS₂ layer to the Ag surface.

The origin of the splitting of the A_1' mode has been the subject of debate. In the works we discussed so far, n-type doping induced by the metal contact is considered responsible for the presence of a low-frequency component of A_1' . However, other authors have proposed different interpretations. Pollmann et al. [16] used the exfoliation technique to study the MoS₂/Au interface on polycrystalline Au films and Au(111) single crystals. The Raman spectrum of mono-layer MoS₂ shows the E_{2g}^1 mode at 379 cm⁻¹, downshifted compared to MoS₂ on SiO₂ due to tensile strain in the MoS₂ lattice. The A_{1g} mode is split, with a low-frequency component ($A_{1g, \text{reduced}}$) at 397 cm⁻¹ and the other one at approximately the same frequency as in MoS₂/SiO₂. To verify that the $A_{1g, \text{reduced}}$ mode is an A-type MoS₂ Raman mode, they performed polarization-dependent Raman spectroscopy and found that this mode behaves like the A_{1g} mode, when changing from a parallel-polarized configuration (xx) to a cross-polarized configuration (xy) [22]. The intensity ratio $A_{1g, \text{reduced}}/A_{1g}$ increases with the smoothness of the Au surface. The ratio is highest for the mono-layer MoS₂ on the very smooth surface of the Au(111) single crystal and decreases as the Au surface becomes rougher. Therefore, the emergence of the $A_{1g, \text{reduced}}$ mode is caused by the direct MoS₂-Au contact. However, Kelvin probe force microscopy (KPFM) measurements do not support the hypothesis of n-type doping as the main cause for the downshift of the A_{1g} mode. X-ray photoelectron spectroscopy (XPS) data provide evidence for the emergence of mid gap states due to a sulfur-mediated spreading of Mo *d* orbitals into the band gap. As previously predicted by Gong et al. [19], this effect causes Fermi level pinning and weakens the Mo-S bond. The origin of the low-frequency A_{1g} mode is thus attributed to the electron occupation of mid gap states, which weakens the Mo-S bond in the region of close contact between Au and MoS₂.

3.3. Growth of MoS₂ on Metal Substrates

The two fabrication approaches described above produce metal-MoS₂ interfaces that are likely to form nonuniform contact between the metal film and the MoS₂ layer, due to surface roughness and airborne contaminants. Exfoliation onto the atomically flat surface of a metal single crystal tackles the roughness issue but makes the identification of MoS₂ flakes by optical microscopy more problematic. Growing MoS₂ directly on a metal surface is an alternative approach that can produce mono-layer MoS₂ in a controlled atmosphere, reducing the contamination level and ensuring a uniform MoS₂-metal interface. Different techniques have been studied to synthesize MoS₂ layers on metals. For instance, CVD in a furnace apparatus has been shown to be a viable route to grow mono-layer MoS₂ on Au, starting from MoO₃ and S precursors [17,40]. A different CVD method, based on Mo deposition in a H₂S atmosphere, has been originally developed by the Besenbacher's group [57] and extensively used to prepare mono-layer MoS₂ on Au(111) under ultra-high vacuum (UHV) conditions for surface science investigations [18,58–60]. Recently, we reported on the fabrication of the cm-scale mono-layer MoS₂ on Au(111) and Ag(111) by pulsed laser deposition (PLD) in UHV, an alternative physical vapor deposition (PVD) approach that allowed us to study MoS₂ and MoS₂/WS₂ heterostructures by scanning tunneling microscopy (STM) and Raman spectroscopy [41–43,61].

STM studies of mono-layer MoS₂ on Au(111) show a moiré superstructure due to the lattice mismatch between MoS₂ (3.16 Å in-plane lattice constant) and Au(111) (2.89 Å) (Figure 5a,b). Low-energy electron diffraction (LEED) patterns revealed that the MoS₂ lattice is aligned to the high-symmetry directions of Au(111) and the mismatch causes 10 MoS₂ unit cell to coincide with 11 Au(111) cells, generating a long-range ordered hexagonal moiré superlattice [18]. The moiré unit cell (black line in Figure 5b) contains three regions with different stackings of MoS₂ on the top Au layer: one top-site and two hollow-site alignments, corresponding to fcc and hcp stackings. The stacking geometry affects the local equilibrium distance and therefore the local interaction between MoS₂ and Au, also resulting in a

modulation of the local electronic properties [60]. The moiré periodicity measured by STM is ~ 3.2 nm [18,58,60]. The 10/11 MoS₂/Au coincidence therefore imposes a $\sim 1\%$ biaxial tensile strain on MoS₂, in agreement with STM measurements of a ~ 3.2 Å MoS₂ lattice parameter, which is slightly larger than the relaxed value.

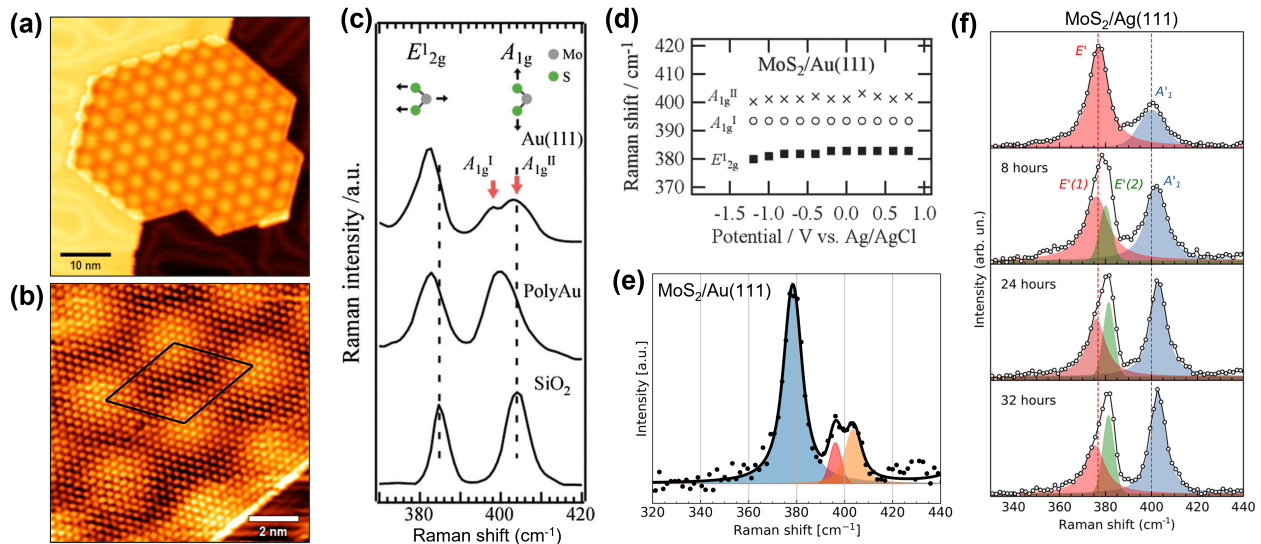


Figure 5. (a) STM image of a mono-layer MoS₂ islands on Au(111) produced by PLD. The hexagonal pattern of bright spots is the moiré superstructure. Reproduced from ref. [41] under CC-BY-NC license. (b) Atomic resolution STM image of mono-layer MoS₂/Au(111). The moiré unit cell is indicated by the black line. Reproduced from ref. [62] under CC-BY license. (c) Raman spectra (excitation wavelength: 532 nm) of mono-layer MoS₂/Au(111) (top), MoS₂/polyAu (middle), and MoS₂/SiO₂ (bottom), respectively. (d) Position of MoS₂/Au(111) Raman modes (revealed in (c), top spectrum) extracted by electrochemical Raman spectra under different potentials. (c,d) reproduced with permission from ref. [40]. (e) Raman spectrum of mono-layer MoS₂/Au(111) grown by PLD (excitation wavelength: 457 nm). Adapted from ref. [43] under CC-BY license. (f) Evolution of Raman spectra of mono-layer MoS₂ grown on Ag(111) on PLD (excitation wavelength: 457 nm). Reproduced from ref. [42] under CC-BY license.

Yasuda et al. [40] proposed that the stacking variation in the moiré unit cell is the origin of the A_1' mode splitting. They deposited mono-layer MoS₂ on Au(111) and polycrystalline Au by CVD, using MoS₂ and S powders as precursors in a quartz furnace. The corresponding Raman spectra are shown in Figure 5c, compared to the spectrum of CVD MoS₂ on SiO₂. In MoS₂/Au(111), besides the downshift of E_{2g}^1 , the splitting of the A_{1g} mode is resolved, with a low-frequency component (A_{1g}^I) at 398 cm⁻¹ and a high-frequency one (A_{1g}^{II}) at 403 cm⁻¹. Notably, the A_{1g} mode of MoS₂ on polycrystalline Au is not split, and its intensity is comparable to that of E_{2g}^1 , in contrast to the lower relative intensity of the two A_{1g} components in MoS₂/Au(111). Electrochemical Raman spectra were acquired under different potentials to investigate the dependence of the Raman modes on doping. As shown in Figure 5d, the peak frequency of the Raman modes of MoS₂/Au(111) does not change significantly with the applied potential, suggesting that the A_1' splitting is not a doping effect but is rather related to strain. Since the A_1' mode does not split on polycrystalline Au, the authors argued that the strain is associated with the specific stacking registry between MoS₂ and Au(111), which periodically varies in the moiré pattern. In particular, the stronger hybridization of S atoms in the on-top positions locally affects the S-Au bond, introducing an out-of-plane strain component that ultimately results in the observed splitting of the A_1' mode.

The growth of MoS₂ under UHV conditions on atomically flat and clean single-crystal metal surfaces is the ideal way to achieve a homogeneous MoS₂-metal interface, suitable

for fundamental studies. However, Raman spectroscopy is not a typical surface science technique, and its application to the study of UHV-grown MoS₂/metal systems is still limited to a few works [41–43,63]. We recently combined UHV STM with ex-situ Raman spectroscopy to study the surface and interface properties of mono-layer MoS₂ grown on Au(111) and Ag(111) by PLD [41,42]. Two representative STM images of our PLD-grown MoS₂/Au(111) are reported in Figure 5a,b, showing the well-ordered moiré pattern and high surface quality of the MoS₂ layer. In agreement with previous works, the Raman spectrum (Figure 5e) shows the E' mode centered at 378 cm⁻¹, and the A'_1 mode split in two components (396 and 403 cm⁻¹).

It is important to notice that Raman spectra of MoS₂ grown on metals can be affected by lateral confinement effects. As discussed in Section 2 regarding the Raman response of defective MoS₂, the lateral confinement breaks the long-range crystalline order and relaxes the fundamental Raman selection rule $\mathbf{q} \approx 0$, where \mathbf{q} is the phonon wavevector. As a result, the contribution of phonon states away from the zone center and the dispersion of phonon bands can influence the Raman spectrum. Depending on the growth technique, the size of crystalline domains and the defect density can vary significantly. On Au(111) or Ag(111), the MoS₂ lattice can grow in two different crystallographic orientations, and domain boundaries are commonly observed between differently oriented domains. The linear size of such domains can be as small as few tens nanometers, as observed for instance in PLD-grown MoS₂ on Au(111) [41].

Ag(111) has almost the same surface structure as Au(111), with Au and Ag being both fcc crystals with 4.065 and 4.079 Å lattice constants, respectively [64]. As a result, mono-layer MoS₂ on Ag(111) has the same structural features as on Au(111), with a characteristic hexagonal moiré pattern showing the same appearance and periodicity in STM data [42]. The corresponding Raman spectrum is shown in the top panel of Figure 5f. The E' mode is at 377 cm⁻¹, and the A'_1 mode is centered at 400 cm⁻¹. In this case, we do not observe a clear splitting of the A'_1 mode, as highlighted by the Voigt fitting of the peak. We note, however, that the peak position approximately corresponds to the average position of the two A'_1 components of MoS₂/Au(111). This Raman spectrum (Figure 5f, top panel) has been measured immediately after the sample exposure to air. Surprisingly, the spectrum changes with increasing exposure time to air, as shown in the other three panels of Figure 5f. After just a few hours of air exposure, the A'_1 mode starts shifting upward and becoming relatively more intense. The E' mode develops a second component at higher frequency ($E'(2)$ green curve) that gradually upshifts, while the low-frequency component ($E'(1)$) maintains its original position. The upshift of Raman modes and the increase in A'_1/E' intensity ratio suggest that the exposure to ambient conditions weakens the MoS₂-Ag interaction. The coexistence of two contributions, $E'(1)$ and $E'(2)$, to the in-plane vibration can be attributed to the simultaneous sampling of regions where MoS₂ strongly interacts with Ag and regions where such interactions are weaker. The gradual intensity decrease in $E'(1)$ against $E'(2)$ suggests that the regions of weak interaction become predominant with increasing air exposure time. With the support of further Raman and XPS data, we proposed that this aging effect is caused by water intercalation at the MoS₂/Ag interface, which reduces the interaction between MoS₂ and Ag. Therefore, the ambient conditions may significantly affect the interface between MoS₂ and metals over a relatively short time, and care must be taken in Raman studies of these systems to reduce the influence of air exposure on the recorded spectra.

In conclusion of this Section, Table 1 summarizes the positions of the E' and A'_1 modes of mono-layer MoS₂ reported in some of the discussed MoS₂-metal heterosystems.

Table 1. Peak frequencies (in cm^{-1}) of the E' and A'_1 modes in different heterostructures between metals and mono-layer MoS_2 . Double line entries indicate that a splitting is resolved and the frequencies of the two contributions are reported.

System	E'	A'_1
MoS_2 on SiO_2 ^a	~384	~403
Ag nanoparticles on MoS_2 ^b	~375 ~383	~394 ~402
MoS_2 exfoliated on (15 nm)Au ^c	378.2 ± 0.6 -	396.4 ± 0.3 403.7 ± 0.2
MoS_2 exfoliated on (5 nm)Au ^d	379 -	397 ~403
CVD-grown MoS_2 on Au(111) ^e	~380 -	398 403
PLD-grown MoS_2 on Au(111) ^f	378 -	396 403
PLD-grown MoS_2 on Ag(111) ^g	377	400

^a Ref. [24]; ^b Ref. [36]; ^c Ref. [37]; ^d Ref. [16]; ^e Ref. [40]; ^f Ref. [41,43]; ^g Ref. [42].

4. Conclusions and Perspectives

Raman spectroscopy studies of MoS_2 interacting with metals show remarkable differences compared to freestanding MoS_2 . The contact with metals modifies the MoS_2 structural and electronic properties, and this influence has profound effects on the vibrational modes. The impact of these effects on Raman spectra depends on the characteristics of the metal- MoS_2 interface and therefore on the fabrication technique used to produce the heterosystem. The MoS_2 -Au heterosystem has been one of the most studied so far, partly because exfoliation of MoS_2 on a clean Au surface produces mono-layer flakes of relatively large area. The interaction with Au affects the in-plane E' and the out-of-plane A'_1 vibrational modes, and it breaks the reflection symmetry in the basal MoS_2 plane, thus activating modes that are silent in freestanding mono-layer MoS_2 . The E' mode typically downshifts by $5\text{--}6 \text{ cm}^{-1}$, compatibly with an average $\sim 1\%$ in-plane biaxial tensile strain induced by Au. The A'_1 mode shows a lower relative intensity and an intriguing splitting whose origin is still debated. These variations make impossible to infer the number of layers in MoS_2 interacting with metals, by using the well-known relation between the frequency distance of the two main Raman modes and the MoS_2 thickness.

Raman investigations of model systems are necessary to understand in detail the physical mechanisms behind the anomalous Raman spectra. The synthesis of mono-layer MoS_2 on single-crystal metal surfaces under UHV conditions is the most promising fabrication approach to produce morphologically uniform and atomically clean MoS_2 -metal interfaces for fundamental studies. In addition to traditional UHV surface science techniques, this approach would benefit from the integration of in situ Raman spectroscopy as the air exposure of MoS_2 -metal samples can alter the interface due to the intercalation of contaminants. The experimental work should be complemented by theoretical investigations of metal-supported MoS_2 . While the theoretical modeling of freestanding MoS_2 is well-established, the calculation of Raman spectra of metal-supported MoS_2 has been addressed by very few works [38,65]. As different effects may contribute to the anomalous behavior of Raman modes, theoretical calculations are necessary to disentangle such contributions and provide quantitative insight into the interpretation of Raman spectra.

The effects of the interaction with metals discussed in this review are not limited to MoS_2 but are common to the other semiconducting TMDs. Raman studies of 2D MoS_2 interacting with metals can access the interface properties of TMD-metal systems and inform the design of efficient metal contacts as well as the development of metal-assisted synthesis methods.

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